devices 100 and 500 so as to emit light having a wavelength different from the light generated by the semiconductor devices 100 and 500. Accordingly, the emission of light may be controlled to have different colors including white light.

[0145] For example, in a case in which the semiconductor devices 100 and 500 emit blue light, white light may be emitted through a combination thereof with yellow, green, and red and/or orange phosphors. Also, the semiconductor devices 100 and 500 may be configured to include at least one LED chip emitting purple, blue, green, red, or infrared (IR) light. For example, the semiconductor device packages 1000 and 2000 may adjust a color rendering index (CRI) in a range from a level of light with a CRI of 40 to a level of light with a CRI of 100, and may generate various types of white light having a color temperature in a range of about 2,000K to 20,000K. Also, the color may be adjusted by generating visible purple, blue, green, red, orange light, or IR light, corresponding to a surrounding atmosphere or desired mood, as necessary. Also, light from within a desired, or alternatively predetermined wavelength known to stimulate plant growth may be generated.

[0146] White light generated by combining yellow, green, and red phosphors with a blue LED and/or combining at least one of a green LED and a red LED therewith may have two or more peak wavelengths, and may be positioned in a segment linking (x, y) coordinates of (0.4476, 0.4074), (0.3484, 0.3516), (0.3101, 0.3162), (0.3128, 0.3292), and (0.3333, 0.3333) in the CIE 1931 color space illustrated in FIG. 21. Alternatively, the white light may be positioned in an area surrounded by the segment and a black body radiation spectrum. The color temperature of the white light may be in a range of 2,000K to 20,000K.

[0147] Phosphors applicable to the example embodiment may have a composition and a color as follows.

[0148] Oxide-based phosphors: yellow and green  $Y_3Al_5O_{12}$ :Ce,  $Tb_3Al_5O_{12}$ :Ce,  $Lu_3Al_5O_{12}$ :Ce

[0149] Silicate-based phosphors: yellow and green (Ba, Sr)<sub>2</sub>SiO<sub>4</sub>:Eu yellow and orange (Ba, Sr)<sub>3</sub>SiO<sub>5</sub>:Ce

[0150] Nitride-based phosphors: green β-SiAlON:Eu, yellow La<sub>3</sub>Si<sub>6</sub>N<sub>11</sub>:Ce, orange α-SiAlON:Eu, red CaAlSiN<sub>3</sub>:Eu, Sr<sup>2</sup>Si<sub>5</sub>N<sub>8</sub>:Eu, SrSiAl<sub>4</sub>N<sub>7</sub>:Eu, SrLiAl<sub>3</sub>N<sub>4</sub>:Eu, Ln<sub>4</sub>-x(EuzM<sub>1</sub>-z)xSi<sub>12</sub>-yAlyO<sub>3</sub>+x+yN<sub>18</sub>-x-y (0.5≤x≤3, 0<z<0.3, 0<y≤4), where Ln denotes an element selected from the group consisting of or including IIIA group elements and rare earth elements, and M denotes at least one element selected from the group consisting of or including calcium (Ca), barium (Ba), strontium (Sr), and magnesium (Mg).

[0151] Fluoride-based phosphors: KSF red  $K_2SiF_6$ : $Mn^{4+}$ ,  $K_2TiF_6$ : $Mn^{4+}$ ,  $NaYF_4$ : $Mr^{40}$  +,  $NaGdF_4$ : $Mn^{4+}$ .

[0152] In general, phosphor compositions need to conform to Stoichiometric requirements, and each element may be substituted with a different element within the same group in the perodic table of elements. For example, Sr may be substituted with Ba, Ca, Mg, or the like, in the alkaline earth metal group II while yttrium (Y) may be substituted with terbium (Tb), lutetium (Lu), scandium (Sc), gadolinium (Gd), or the like, in the lanthanide group. Also, europium (Eu), or the like, an activator, may be substituted with cerium (Ce), Tb, praseodymium (Pr), erbium (Er), ytterbium (Yb), or the like, based on a desired energy level. In addition, the activator may be used alone, or a co-activator, or the like, may be further included to change characteristics.

[0153] Further, a material such as a QD may be used as a phosphor substitute material, or the phosphor and the QD may be used in combination or alone.

[0154] The QD may have a structure including a core such as cadmium selenide (CdSe) and indium phosphide (InP) having a diameter of about 3 to 10 nanometers (nm), a shell such as zinc sulfide (ZnS) and zinc selenide (ZnSe) having a thickness of about 0.5 to 2 nm, and a ligand for stabilizing the core and the shell, and may provide various colors based on the size thereof.

[0155] FIGS. 22 and 23 are cross-sectional views illustrating examples of backlight units using semiconductor devices according to example embodiments.

[0156] Referring to FIG. 22, a backlight unit 3000 may include a light source 3001 mounted on a substrate 3002, and at least one optical sheet 3003 disposed thereabove. As the light source 3001, the semiconductor device package having the structure described above with reference to FIGS. 19 and 20 or a same or similar structure thereto may be used, or a semiconductor device may be directly mounted on the substrate 3002 in a so-called COB type manner.

[0157] The light source 3001 in the back light unit 3000 illustrated in FIG. 22 may emit light upwardly in a direction in which a liquid crystal display (LCD) device is disposed. However, in a back light unit 4000 of another example illustrated in FIG. 23, a light source 4001 mounted on a substrate 4002 may emit light in a lateral direction such that the emitted light may be incident onto a light guiding panel 4003 to be converted into a form of a surface light source. Light, having passed through the light guiding panel 4003, may be dissipated upwardly, and a reflective layer 4004 may be disposed below the light guiding panel 4003 to improve light extraction efficiency.

[0158] FIGS. 24 and 25 are exploded perspective views illustrating examples of lighting apparatuses using semiconductor devices according to example embodiments.

[0159] Referring to FIG. 24, a lighting apparatus 5000 is illustrated as a bulb-type lamp, and may include a light emitting module 5010, a driving unit 5020, and an external connection unit 5030. In addition, the lighting apparatus 5000 may further include an outer structure such as an external housing 5040, an internal housing 5050, and a cover unit 5060.

[0160] The light emitting module 5010 may include a semiconductor device 5011 having a structure identical to or similar to the semiconductor device 100 of FIG. 18 and a circuit substrate 5012 on which the semiconductor device 5011 is mounted. In the example embodiment, an example in which a single semiconductor device 5011 is mounted on the circuit, substrate 5012 is exemplified; however, as necessary, a plurality of semiconductor devices may be mounted thereon. Further, the semiconductor device 5011 may not be mounted directly on the circuit substrate 5012, and may be mounted thereon subsequently to being manufactured in the package form illustrated in FIGS. 19 and 20.

[0161] The external housing 5040 may serve as a heat dissipation unit, and may include a heat dissipation plate 5041 in direct contact with the light emitting module 5010 to enhance heat dissipation effects, and heat dissipation fins 5042 surrounding a side surface of the external housing 5040. The cover unit 5060 may be mounted on the light emitting module 5010, and may have a convex lens shape. The driving unit 5020 may be installed in the internal housing 5050, and may be connected to the external con-